

Notice of References Cited	Application/Control No. 10/632,598	Applicant(s)/Patent Under Reexamination SHEPHERD ET AL.	
	Examiner Michael K. Luhrs	Art Unit 2824	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-5,733,662	03-1998	Bogachek, Valery	427/446
*	B	US-6,083,355	07-2000	Spence, Paul	204/164
*	C	US-5,723,027	03-1998	Serole, Bernard	204/164
*	D	US-5,468,357	11-1995	Upadhyia et al.	204/173
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	R.E. Hummel and S.-S. Chang (1992) Appl. Phys. Lett. 61:1965-7.
	V	Silicon Based Materials and Devices, edited by Nalwa, Hari Singh, Academic Press, volume 1, (chapter 6 by R.E. Hummel) pp. 238-266.
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.